

SEM Top view

Graphical analysis result

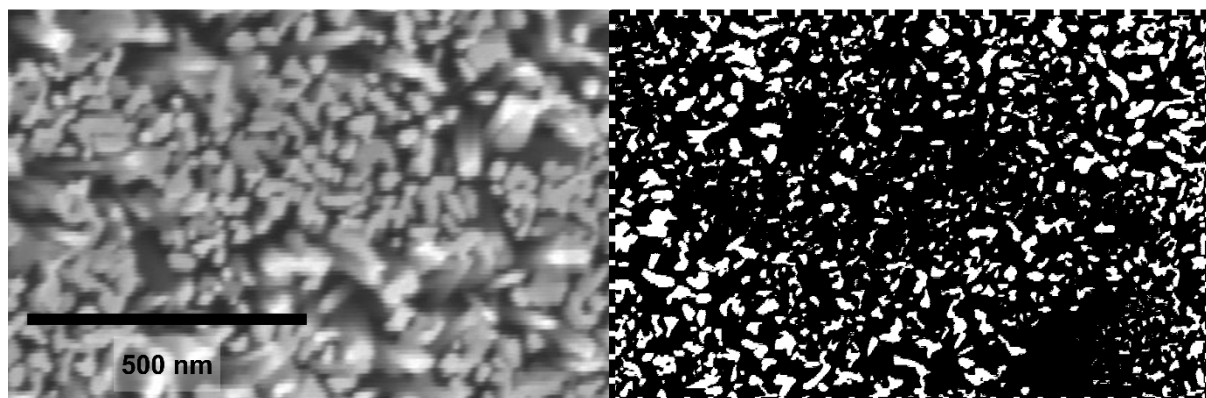


Figure S1. SEM image of GaN NRs

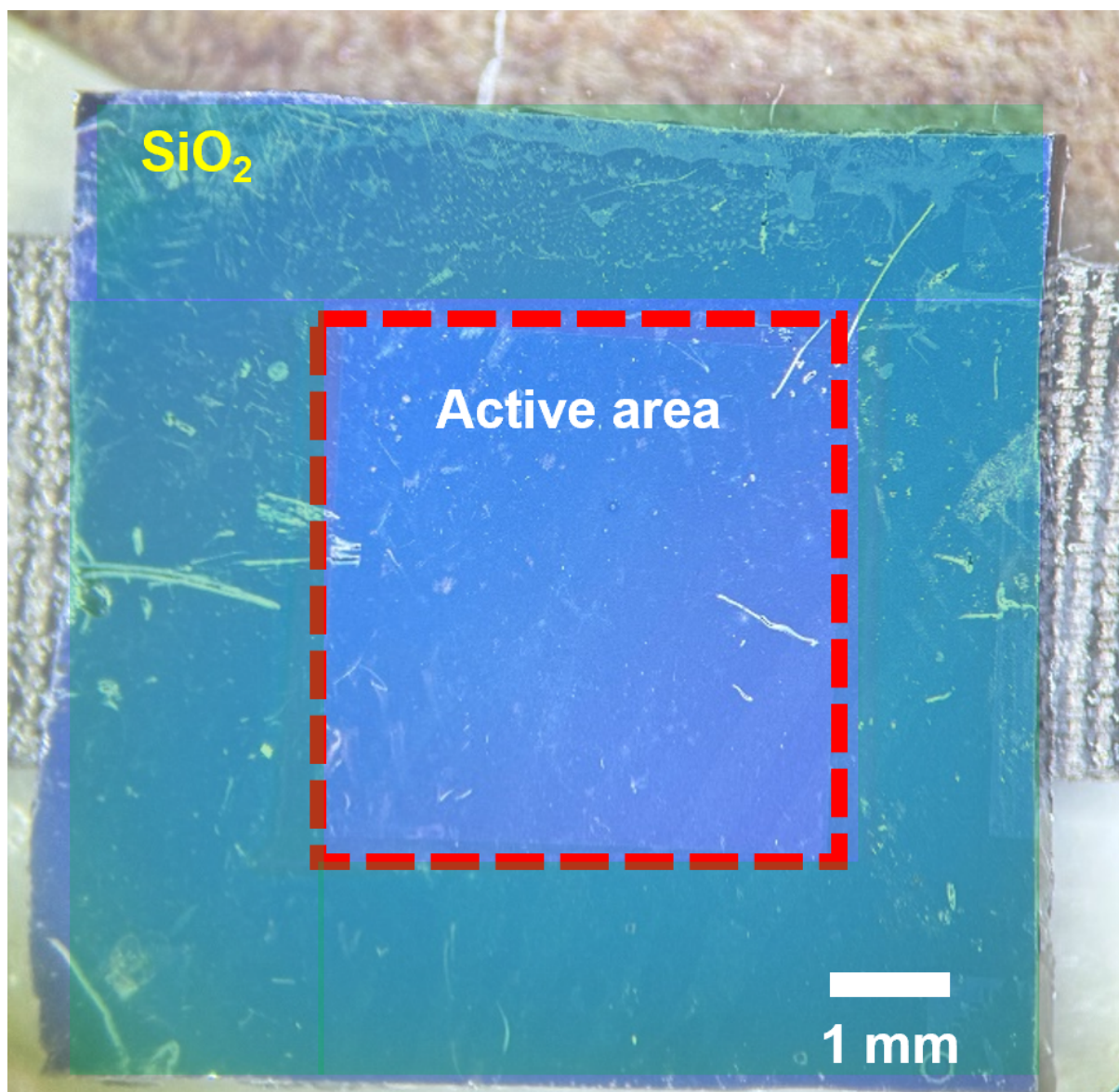


Figure S2 Photograph of the fabricated SH-PD.

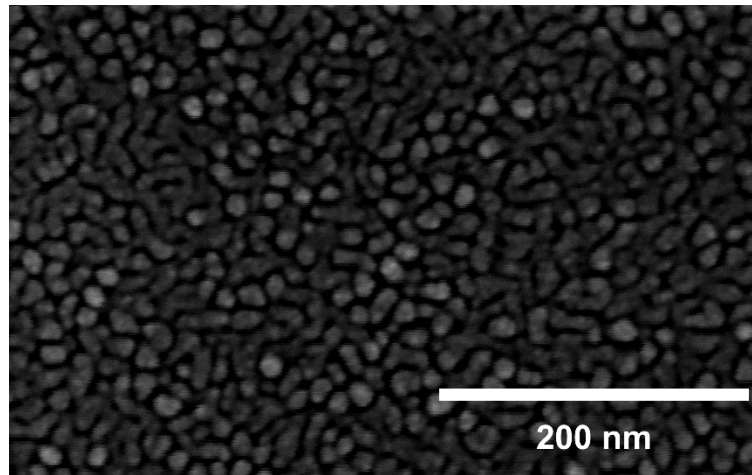


Figure S3 FE-SEM image of ZTN thin film

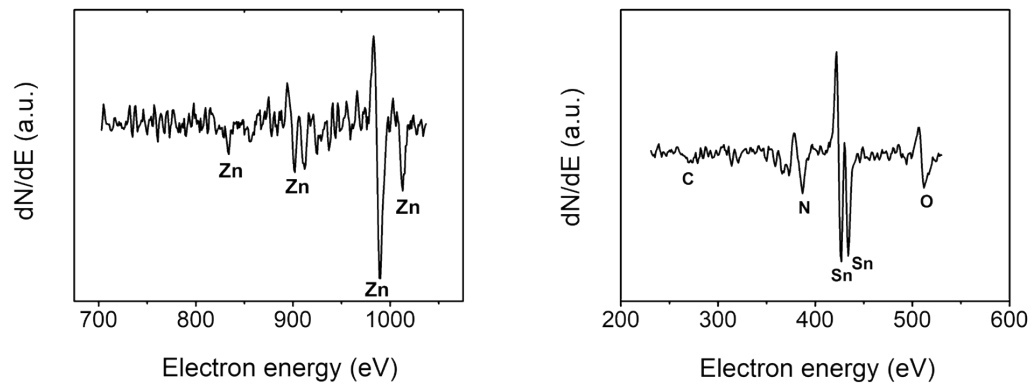


Figure S4 AES results of ZTN thin film

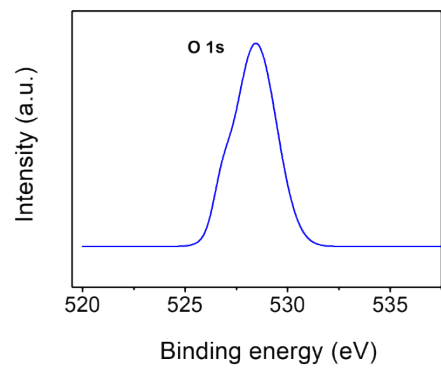
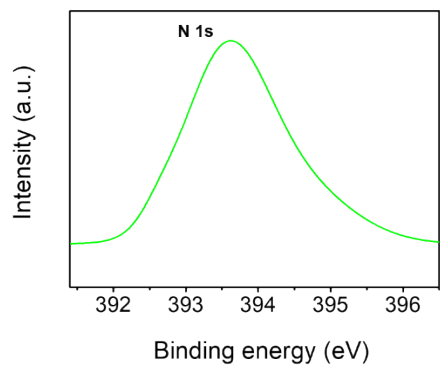
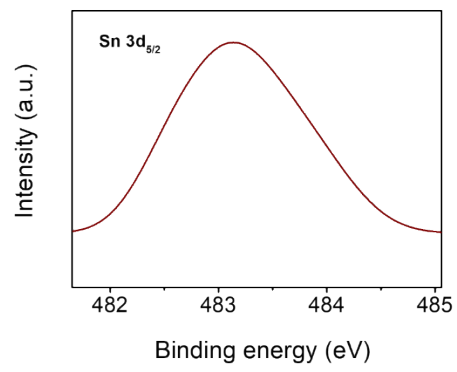
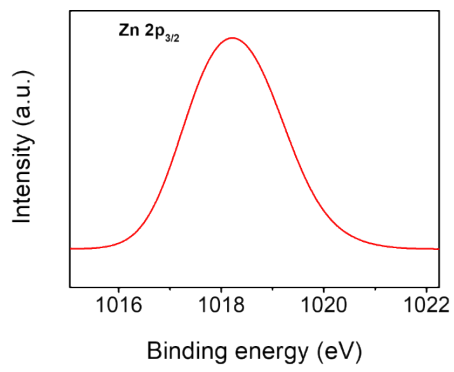


Figure S5 XPS results of ZTN thin film

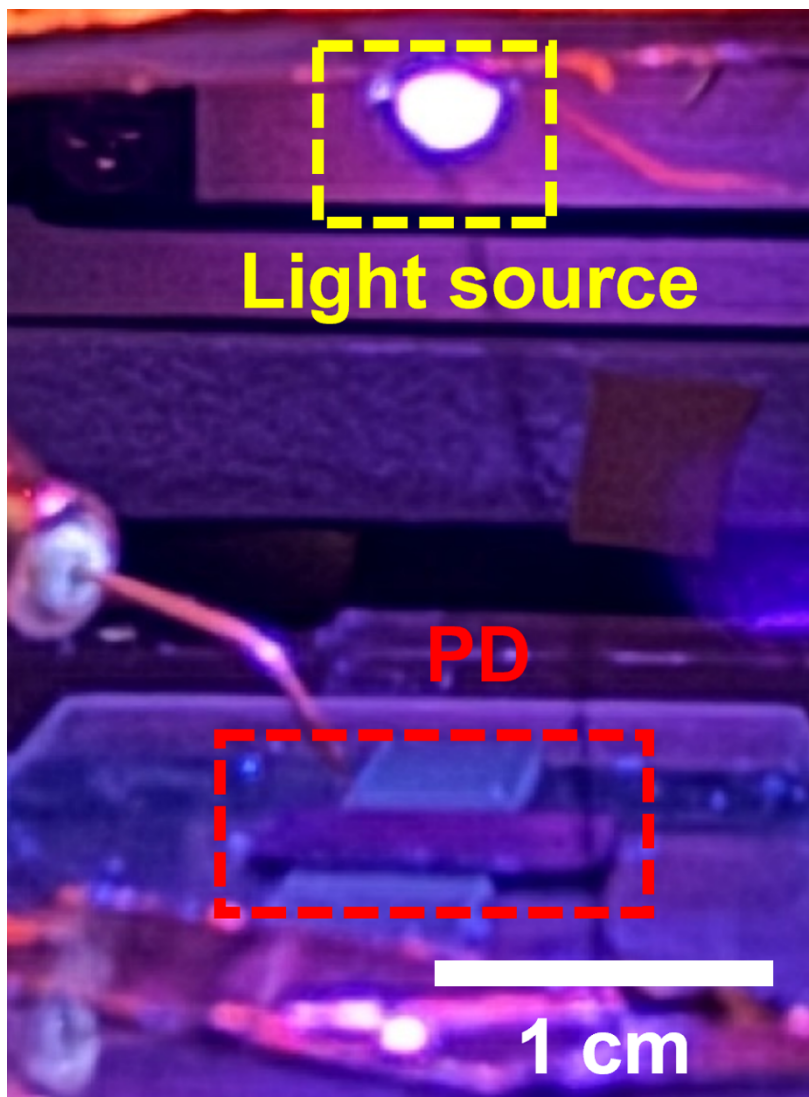


Figure S6 Experimental set-up for measuring optical/electrical properties of the devices.

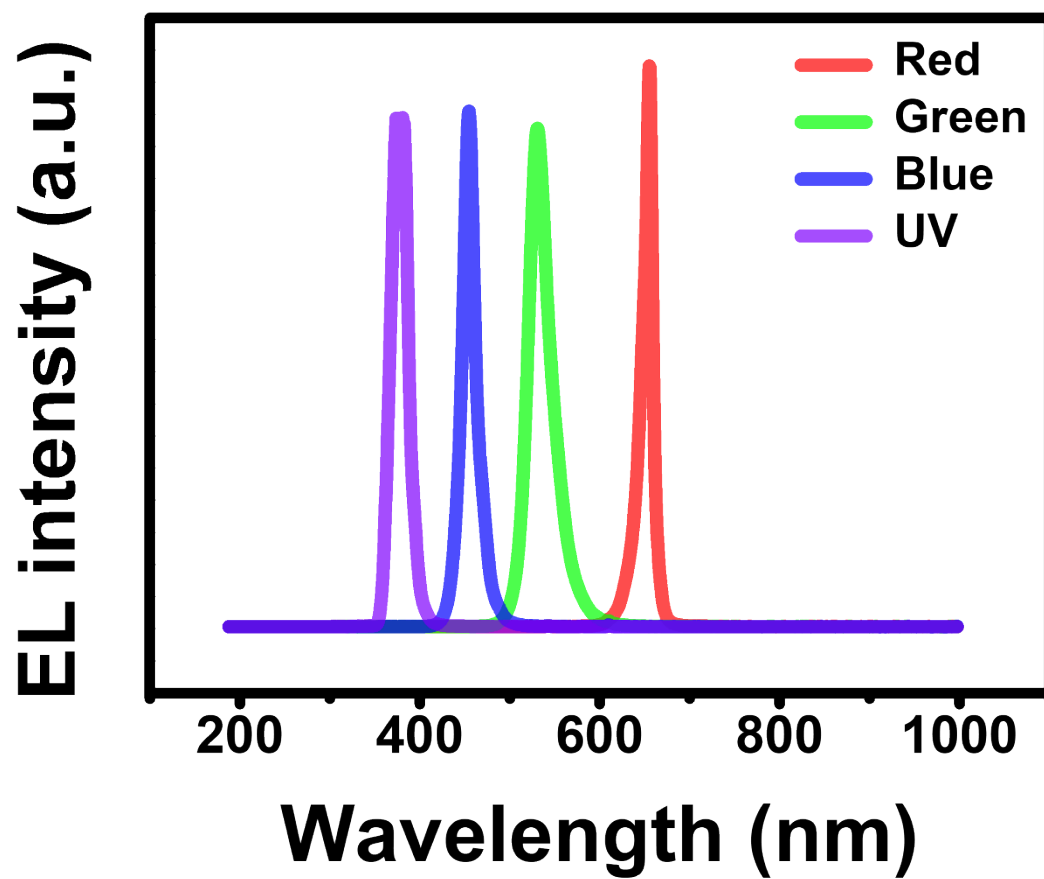


Figure S7 EL spectrum of the conventional light sources (UV, blue, green and red light).

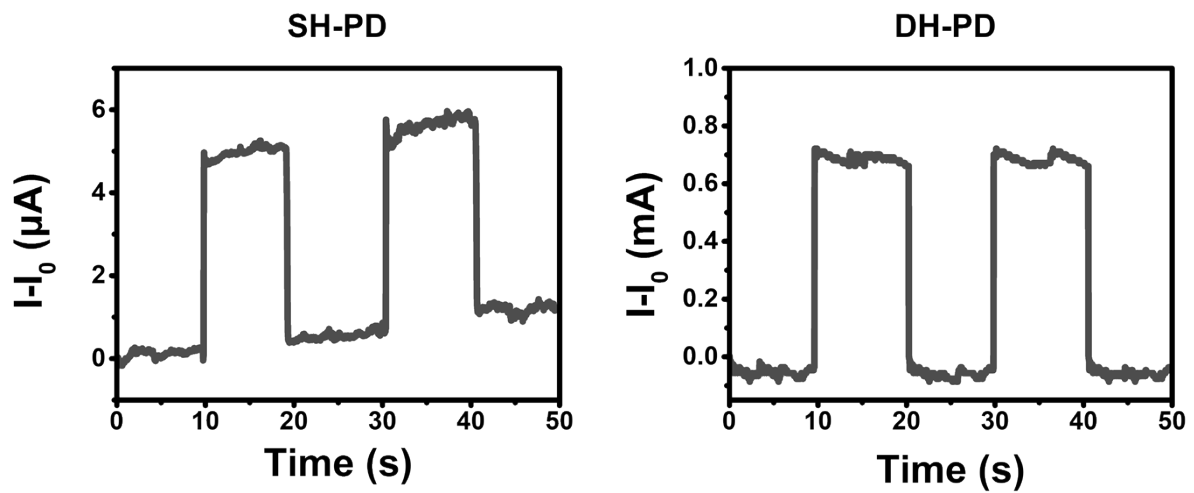


Figure S8 Operation testing results of SH-PD (left) and DH-PD (right)

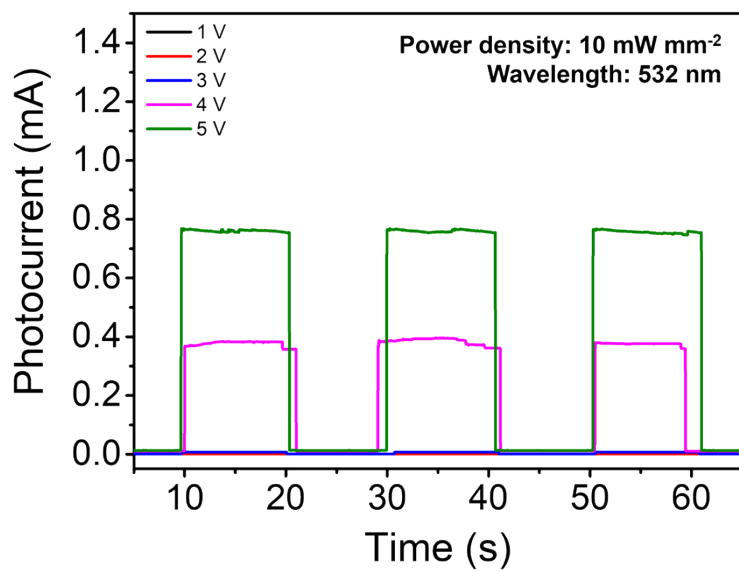


Figure S9 Voltage-dependent device operation test

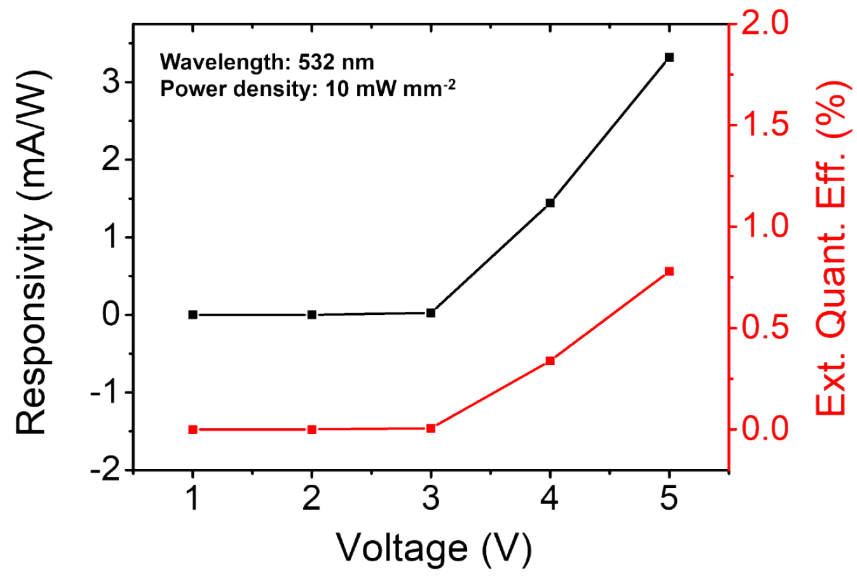


Figure S10 R and EQE value of voltage-dependent on/off test

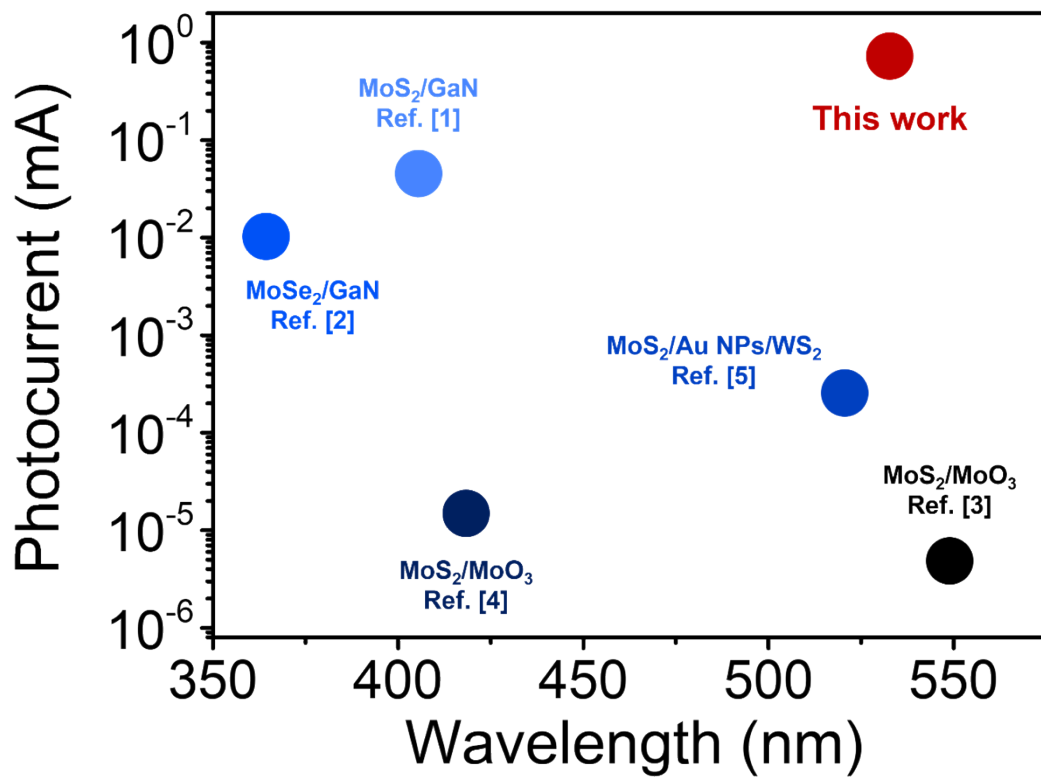


Figure S11. The performance comparison result of reported heterojunction-based PDs

| | thickness [nm] | Bulk concentration N_b [cm^{-3}] | Mobility μ [$\text{cm}^2 \text{V}^{-1} \text{s}^{-1}$] |
|----------------------|-------------------|--|---|
| ZTN thin film | 242.1 | -2.39E+19 | 1.33E+01 |

Table S1 Bulk carrier concentration and mobility of ZTN thin-film

| Voltage | Photocurrent | Dark current | Responsivity | EQE |
|---------|---------------|---------------|-----------------|-------------------------|
| 1 V | 0.504 μ A | 0.315 μ A | 0.759 μ A/W | 1.78×10^{-4} % |
| 2 V | 1.020 μ A | 0.572 μ A | 1.81 μ A/W | 4.25×10^{-4} % |
| 3 V | 7.341 μ A | 1.000 μ A | 25.3 μ A/W | 5.95×10^{-3} % |
| 4 V | 37.14 μ A | 10.81 μ A | 1.44 mA/W | 3.38×10^{-1} % |
| 5 V | 733.7 μ A | 13.46 μ A | 3.32 mA/W | 7.79×10^{-1} % |

Table S2 Summary of voltage-dependent on/off test

| Material | Photocurrent | Dark current | Wavelength | ΔI | Ref |
|--|--------------|--------------|------------|--------------|-----------|
| MoS ₂ /GaN | 40.5 μ A | 0.2 μ A | 405 nm | 40.3 μ A | [1] |
| MoSe ₂ /GaN | 10.5 μ A | 0.95 μ A | 365 nm | 9.55 μ A | [2] |
| MoS ₂ /MoO ₃ | 4.7 nA | 1.3 pA | 550 nm | 4.7 nA | [3] |
| MoS ₂ /MoO ₃ | 15.56 nA | 6 pA | 420 nm | 15.56 nA | [4] |
| MoS ₂ /Au NPs/WS ₂ | 230 nA | 1.1 pA | 520 nm | 230 nA | [5] |
| ZTN/GaN/Si | 733 μ A | 13 μ A | 532 nm | 720 μ A | This work |

Table S3 The photocurrent, dark current and wavelength comparison result of reported heterojunction-based PDs

- 1 M. Moun, M. Kumar, M. Garg, R. Pathak, and R. Singh, Understanding of MoS₂/GaN Heterojunction Diode and its Photodetection Properties, *Sci. Rep.*, 2018, **8**, 11799.
- 2 H. K. Sandhu, J. W. John, A. Jakhar, A. Sharma, A. Jain, and S. Das, MoSe₂/n-GaN Heterojunction Induced High Photoconductive Gain for Low-Noise Broadband Photodetection from Ultraviolet to Near-Infrared Wavelengths, *Adv. Mater. Interfaces.*, 2022, **9**, 2102200.
- 3 H. Li, T. Zhang, Z. Yi, X. Chen, Z. Dai, and J. Tan, High Sensitive and Stable UV–Vis Photodetector Based on MoS₂/MoO₃ vdW Heterojunction, *ACS Appl. Mater. Interfaces*, 2024, **16**, 33829-33837.
- 4 R. Singh, M. Kumar, U. Kim, and H. Seo, Self-Powered and High-Performance Alternating Current Photodetectors to enhance Broadband Photodetection, *Adv. Electron. Mater.*, 2022, **8**, 2200392.
- 5 Z. Lin, P. Luo, W. Zeng, H. Lai, W. Xie, W. Deng, and Z. Luo, Improvement of photoelectric properties of MoS₂/WS₂ heterostructure photodetector with interlayer of Au nanoparticles, *Opt. Mater.*, 2020, **108**, 110191.